

# Oxidative dehydrogenation of ethane to ethylene over alumina-supported vanadium oxide catalysts: Relationship between molecular structures and chemical reactivity

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## Abstract

The influence of vanadium oxide loading in the supported  $\text{VO}_x/\text{Al}_2\text{O}_3$  catalyst system upon the dehydrated surface vanadia molecular structure, surface acidic properties, reduction characteristics and the catalytic oxidative dehydrogenation (ODH) of ethane to ethylene was investigated. Characterization of the supported  $\text{VO}_x/\text{Al}_2\text{O}_3$  catalysts by XPS surface analysis and Raman spectroscopy revealed that vanadia was highly dispersed on the  $\text{Al}_2\text{O}_3$  support as a two-dimensional surface  $\text{VO}_x$  overlayer with monolayer surface coverage corresponding to  $\sim 9 \text{ V/nm}^2$ . Furthermore, Raman revealed that the extent of polymerization of surface  $\text{VO}_x$  species increases with surface vanadia coverage in the sub-monolayer region. Pyridine chemisorption-IR studies revealed that the number of surface Brønsted acid sites increases with increasing surface  $\text{VO}_x$  coverage and parallels the extent of polymerization in the sub-monolayer region. The reducibility of the surface  $\text{VO}_x$  species was monitored by both  $\text{H}_2$ -TPR and in situ Raman spectroscopy and also revealed that the reducibility of the surface  $\text{VO}_x$  species increases with surface  $\text{VO}_x$  coverage and parallels the extent of polymerization in the sub-monolayer region. The fraction of monomeric and polymeric surface  $\text{VO}_x$  species has been quantitatively calculated by a novel UV-Vis DRS method. The overall ethane ODH TOF value, however, is constant with surface vanadia coverage in the sub-monolayer region. The constant ethane TOF reveals that both isolated and polymeric surface  $\text{VO}_x$  species possess essentially the same TOF value for ethane activation. The reducibility and Brønsted acidity of the surface  $\text{VO}_x$  species, however, do affect the ethylene selectivity. The highest selectivity to ethylene was obtained at a surface vanadia density of  $\sim 2.2 \text{ V/nm}^2$ , which corresponds to a little more than  $\sim 0.25$  monolayer coverage. Below  $2.2 \text{ V/nm}^2$ , exposed Al support cations are responsible for converting ethylene to CO. Above  $2.2 \text{ V/nm}^2$ , the enhanced reducibility and surface Brønsted acidity appear to decrease the ethylene selectivity, which may also be due to higher conversion levels. Above monolayer coverage, crystalline  $\text{V}_2\text{O}_5$  nanoparticles are also present and do not contribute to ethane activation, but are responsible for unselective conversion of ethylene to CO. The crystalline  $\text{V}_2\text{O}_5$  nanoparticles also react with the  $\text{Al}_2\text{O}_3$  support at elevated temperatures via a solid-state reaction to form crystalline  $\text{AlVO}_4$ , which suppresses ethylene combustion of the crystalline  $\text{V}_2\text{O}_5$  nanoparticles. The molecular structure-chemical characteristics of the surface  $\text{VO}_x$  species demonstrate that neither the terminal  $\text{V}=\text{O}$  nor bridging  $\text{V}-\text{O}-\text{V}$  bonds influence the chemical properties of the supported  $\text{VO}_x/\text{Al}_2\text{O}_3$  catalysts, and that the bridging  $\text{V}-\text{O}-\text{Al}$  bond represents the catalytic active site for ethane activation.

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## 1. Introduction

Ethane is the second major component of natural gas, which makes it a potential source for ethylene, which is commonly used for the production of low density polyethylene, high density polyethylene, ethylene oxide, as well as many other

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compounds made from C<sub>2</sub> hydrocarbons. Despite this potential source of ethylene, no industrial process currently operates for the conversion of ethane to ethylene [1], but important progress is being made [2]. Oxidative dehydrogenation (ODH) of light alkanes is an energetically efficient process, because the presence of oxygen lowers the thermodynamic restrictions for dehydrogenation [3]. However, the yield to alkenes on most of the catalysts used is not satisfactory, due to the side reactions leading to the formation of CO<sub>x</sub>. Thus, understanding of the parameters that make the catalysts efficient for the heterogeneous catalysis for the oxidative dehydrogenation of ethane is currently very important.

Vanadium-based catalysts are among the most active and selective for ODH of light alkanes. The redox properties of the catalyst are important for reactions which proceed via the Mars-van-Krevelen mechanism. Hydrocarbon molecules react with oxygen associated with the vanadia and the reduced vanadium cations are reoxidized by gas phase molecular O<sub>2</sub>. The average oxidation state during catalytic operation depends on the relative rates of reduction and reoxidation, which for alkane oxidation over supported vanadium oxide catalysts appears to leave the supported oxide essentially oxidized [4].

The molecular structure of the supported VO<sub>x</sub> species has been clearly revealed by the application of several ground breaking in situ spectroscopic investigations during the 1980s [5]. The dehydrated surface VO<sub>x</sub> species are usually exclusively present as isolated surface (–Support–O)<sub>3</sub>–V=O species at low surface VO<sub>x</sub> coverage and the extent of polymerization increases with surface VO<sub>x</sub> coverage, which has only one V–O–support bond per vanadium atom and two being bridging V–O–V bonds. A quantitative method, based on UV–vis diffuse reflectance spectroscopy (DRS), has recently been developed to determine the fraction of monomeric and polymeric surface VO<sub>x</sub> species present in supported VO<sub>x</sub> on silica, alumina and zirconia [6]. This method is also employed in the present investigation of alumina-supported vanadia catalysts.

The activity of supported vanadia catalysts is strongly affected by the interaction with the specific oxide support and texture [1,7]. Alumina supports constitute a family of materials whose importance in the field of heterogeneous catalysis is significant [8]. The solid-state chemistry of aluminum oxides is very complex with several different meta-stable crystal phases forming under different synthesis conditions, and also may involve the cations supported on them (e.g., Mo [9], V [10,11] or Sb [12]). One of the most important features of alumina supports is their surface acidity, and IR spectroscopy coupled with chemisorption of basic chemical probe molecules has been used extensively for determination of acidity [13]. The best results in the determination of the total acidity of alumina supports can be obtained by the adsorption–desorption of pyridine (Py) [14]. In fact Py, although less basic than ammonia, is a fairly hard base that interacts with widely different surface acid sites.

The interaction of the surface vanadia species and the oxide support has a profound effect on the catalytic properties of the supported vanadium oxide catalysts. However, there is no clear relationship between the structure of surface vanadia species

and their reactivity for the ODH of lower alkanes. The objective of this study is to evaluate the effect of vanadium oxide loading on Al<sub>2</sub>O<sub>3</sub> for ethane ODH to ethylene and relate its catalytic performance to changes in surface vanadia molecular structure, surface redox and surface acidic characteristics.

## 2. Experimental

Vanadium oxide was supported on  $\gamma$ -alumina by the incipient wetness impregnation technique [15] to obtain catalyst loading ranging from 1 to 30 wt.% of V<sub>2</sub>O<sub>5</sub> on Al<sub>2</sub>O<sub>3</sub>. The catalysts are referred to as “xVAI”, where “x” represents the weight percent of V<sub>2</sub>O<sub>5</sub> on Al<sub>2</sub>O<sub>3</sub>. The fraction of polymerized surface vanadium oxide species was determined based on the methodology described elsewhere [6]. Surface vanadium loading (V at/nm<sup>2</sup>) was calculated with respect to the BET area of the alumina support.

The BET surface areas of the samples were determined by N<sub>2</sub> adsorption at –196 °C in a Micromeritics system Model 2000 ASAP. The composition of the near-surface region (sampling depth of 3–5 nm) of the supported V<sub>2</sub>O<sub>5</sub>/Al<sub>2</sub>O<sub>3</sub> catalysts was investigated using X-ray photoelectron spectroscopy (XPS). The XPS analysis was performed in a Fisons ESCALAB 200R electron spectrometer equipped with a hemispherical electron analyzer and a Mg K $\alpha$  X-ray source ( $h\nu = 1253.6$  eV) powered at 120 W. A PDP 11/05 computer from DEC was used for collecting and analyzing the spectra. The samples were placed in small copper cylinders and mounted in a transfer rod placed in the pretreatment chamber of the instrument. The base pressure in the ion-pumped analysis chamber was maintained below  $5 \times 10^{-9}$  Torr during data acquisition. The XPS signals were collected for 30–100 min with pass energy of 10 eV, which is typical for collection of high resolution spectra.

The in situ Raman spectra were collected with a Renishaw Micro-Raman System 1000 equipped with a cooled CCD detector (–73 °C) and a holographic super-Notch filter that removes the elastic laser scattering. The samples were excited with the 514.5 nm Ar<sup>+</sup> line. An in situ environmental cell (Linkam, TS-1500) allowed control of catalyst temperature, gas composition and flow rates. The samples were maintained in powder form to minimize mass transfer limitations and ensure that all catalytic material in the cell is exposed to the flowing gases. The spectral resolution is  $\sim 3$  cm<sup>–1</sup> and the spectral acquisition consisted of five 60 s accumulations (300 s) for each sample. The samples for the in situ measurements were initially pretreated in O<sub>2</sub>/He at 450 °C for 4 h prior to any other treatments. The Raman spectra of dehydrated samples were run at 150 °C, after the pretreatment at 450 °C. The temperature-programmed (TP)-Raman studies, TPO- and TPR-Raman, were performed by heating the catalyst sample stepwise in synthetic air or 10% H<sub>2</sub>/Ar, respectively [16]. Although Raman spectroscopy penetrates ca.  $\sim 1$   $\mu$ m in the catalyst, it provides the molecular structures of both surface and bulk phases, particularly for supported oxide, where the supported component is initially located at the surface [15]. The reaction in situ Raman spectra under ethane ODH (C<sub>2</sub>H<sub>6</sub>/O<sub>2</sub>/He molar

ratio = 1/2/8) and DH ( $C_2H_6/He$  molar ratio = 1/8)) reaction conditions were performed using the same reaction feed as in the catalytic runs, further information can be found elsewhere [15,17,18].

The in situ UV–vis DRS spectra were obtained with a Varian Cary 5E UV–vis spectrophotometer employing the integration sphere diffuse reflectance attachment, and an in situ cell (Harrick, HVC-DR2) as described elsewhere [6]. The UV–vis DRS spectra of the bulk vanadate reference compounds were obtained under ambient conditions, and the spectra of the dehydrated supported vanadia catalysts were obtained after the samples were treated at 400 °C in flowing 10%  $O_2/He$  gas (30 mL/min) for 1 h to desorb the adsorbed ambient moisture. The Kubelka–Munk function  $F(R_\infty)$  was extracted from the UV–vis DRS absorbance and the edge energy ( $E_g$ ) for allowed transitions was determined by finding the intercept of the straight line in the low-energy rise of the plot of  $[F(R_\infty)hv]^2$  against  $hv$ , where  $hv$  is the incident photon energy [6].

The  $H_2$  temperature programmed reduction ( $H_2$ -TPR) experiments were run in a Micrometrics equipment model TPR/TPD-2900 fitted with a TCD detector. Samples of ca. 20 mg each were used. The TPR experiments were run in a 10%  $H_2/Ar$  stream, with a heating rate of 10 °C/min and 80  $cm^3/min$  flow rate.

FTIR spectra were collected with a Nicolet equipment model 5ZDX fitted with a DTGS detector. The spectral resolution is  $\sim 4\text{ cm}^{-1}$  and the spectral acquisition consisted of 100 accumulations for each spectrum. Spectra of KBr were subtracted from all spectra. Pyridine adsorption was made at room temperature.

Ethane oxidation was carried out in an isothermal fixed-bed down-flow reactor containing 20 mg of the catalyst. The reaction was evaluated in the temperature range of 450–610 °C at atmospheric pressure. The reaction gas mixture consisted of  $C_2H_6/O_2/He$  (molar ratio = 1/2/8) with a total flow rate of 30  $cm^3/min$ . The TOF values were calculated assuming that all the vanadia is dispersed, which was confirmed by Raman spectroscopy. Conversion is defined as the fraction of the ethane reactant converted to reaction products, selectivity is defined as fraction of reaction products that form ethylene, and the yield is defined as the total amount of ethylene produced (conversion  $\times$  selectivity).

Table 1

Catalysts	Abs. Atom. % $V_2O_5/Al_2O_3$	BET ( $m^2/g$ )	Atom. ratio V/Al-XPS	$V/nm^{2a}$	atV/g
$Al_2O_3$	0	222	0	0	0
1VAI	1.4	221	0.002	0.4	$9.0 \times 10^{22}$
3VAI	4.2	219	0.007	1.3	$2.8 \times 10^{23}$
5VAI	6.9	217	0.014	2.2	$4.6 \times 10^{23}$
10VAI	14.1	217	0.047	4.9	$9.3 \times 10^{23}$
15VAI	18.9	207	0.060	7.0	$1.3 \times 10^{24}$
20VAI	24.9	173	0.074	9.9	$1.7 \times 10^{24}$
25VAI	31.0	165	0.082	13.4	$2.1 \times 10^{24}$
30VAI	39.4	171	0.079	19.4	$2.7 \times 10^{24}$

<sup>a</sup> Referred to the BET area of alumina support (222  $m^2/g$ ).

### 3. Results

#### 3.1. Characterization of fresh catalysts

The physicochemical characteristics of the catalysts are listed in Table 1. From the table, it is observed that the BET surface area decreases with an increase in vanadium oxide loading, which is primarily due to the added mass of the vanadia. The XPS V/Al atomic ratio also increases linearly with vanadium oxide loading up to 20VAI, then levels off. This suggests a high dispersion degree of vanadium oxide species up to a loading between 15VAI and 20VAI (i.e., between 7 and 10 V atoms/ $nm^2$ ), which corresponds to monolayer surface coverage.

##### 3.1.1. In situ Raman spectroscopy studies

The in situ Raman spectra of 0–30%  $VO_x/Al_2O_3$  under dehydrated conditions (450 °C) are presented in Fig. 1. The  $Al_2O_3$  support does not exhibit Raman bands due to the ionic character of the Al–O bond. Crystalline  $V_2O_5$  vibrations at 141, 191, 281, 406, 526, 695 and 993  $cm^{-1}$  are not present at the lower vanadia loadings and are only present above monolayer surface vanadia coverage, which corresponds to  $\sim 9\text{ V}/nm^2$  and is in agreement with the XPS results. The vibration at  $\sim 1010\text{ cm}^{-1}$  arises from the

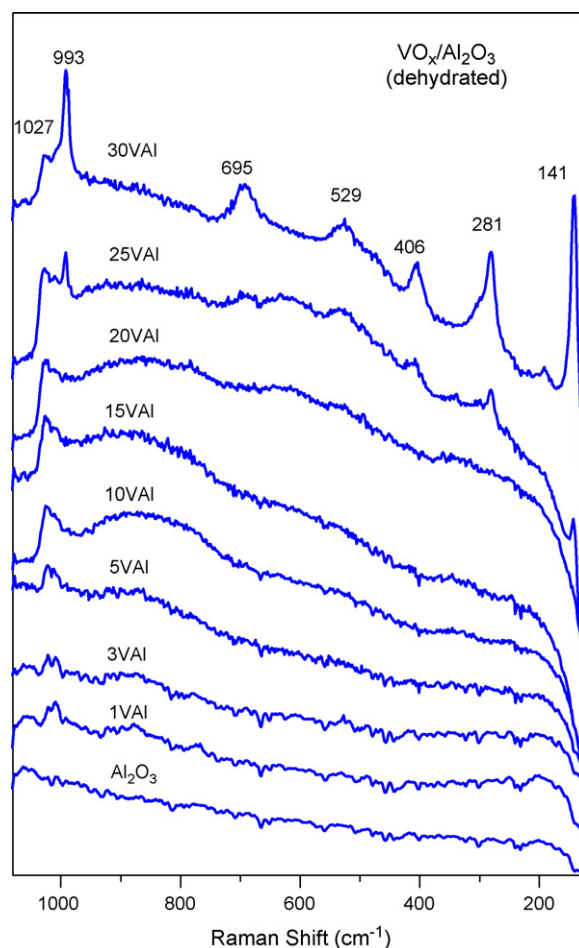


Fig. 1. The in situ Raman spectra of 0–30%  $VO_x/Al_2O_3$  under dehydrated conditions (450 °C).

terminal V=O bond of isolated surface vanadia species (Al-O)<sub>3</sub>-V=O [19], and is the predominant Raman band at low vanadium loading (until ~5VAI). As vanadia loading increases, the terminal V=O vibration shifts to higher frequencies and a broad feature at ~860 cm<sup>-1</sup> also becomes apparent, which has previously been assigned to the vibration of the bridging V–O–Al bond [20]. The Raman band at ~340 cm<sup>-1</sup> is characteristic of the bending mode of the dehydrated surface VO<sub>x</sub> species [21]. In addition, new Raman bands are also present at ~620 and ~780 cm<sup>-1</sup> for high vanadia loaded samples that arise from the symmetric and asymmetric stretching modes of the bridging V–O–V functionality of the polymeric surface vanadia species. The increase of polymeric surface vanadia species with vanadia loading, suggests that Raman band at 1010 cm<sup>-1</sup> correspond to V=O functionality of isolated surface vanadia species and 1023 cm<sup>-1</sup> to V=O functionality of polymeric surface vanadia species.

### 3.1.2. In situ oxidizing environments

The dehydrated 25VAI catalyst was heated stepwise in the in situ Linkam cell in dry air stream. Fig. 2 shows representative Raman spectra. Alumina-supported vanadium oxide catalyst containing the crystalline V<sub>2</sub>O<sub>5</sub> nanoparticles undergo solid-state

reaction to form bulk AlVO<sub>4</sub> (281, 322, 397, 463, 514, 557, 851, 900, 918, 947, 984 and 1012 cm<sup>-1</sup>) [10,11,22] above 570 °C.

### 3.1.3. In situ hydrocarbon reducing environments

Similarly, the dehydrated catalysts were heated stepwise in the in situ cell in the reducing reactive environment of C<sub>2</sub>H<sub>6</sub>/He. The in situ TPR-Raman spectra of 15% V<sub>2</sub>O<sub>5</sub>/Al<sub>2</sub>O<sub>3</sub> are shown in Fig. 3. The Raman bands at 895 cm<sup>-1</sup> (V–O–Al) and 1029 cm<sup>-1</sup> (V=O) significantly decrease with temperature as the extent of reduction of the surface vanadia species progresses.

The H<sub>2</sub>-TPR profiles of the supported VO<sub>x</sub>/Al<sub>2</sub>O<sub>3</sub> catalysts are presented in Fig. 4. The supported 1VAI catalyst exhibits one reduction peak at 550 °C, which shifts progressively to lower values with increasing vanadia coverage up to 15VAI (466 °C). This band then shifts progressively to higher peak temperatures, 503 °C for 30VAI, with increasing vanadia loading above monolayer surface coverage.

The total number and distribution of surface Lewis and Brønsted acid sites of the supported VO<sub>x</sub>/Al<sub>2</sub>O<sub>3</sub> catalysts were determined by the adsorption–desorption of pyridine. The FT-IR spectra of pyridine adsorbed at room temperature and after evacuation at 120 °C are presented in Fig. 5. The surface Lewis

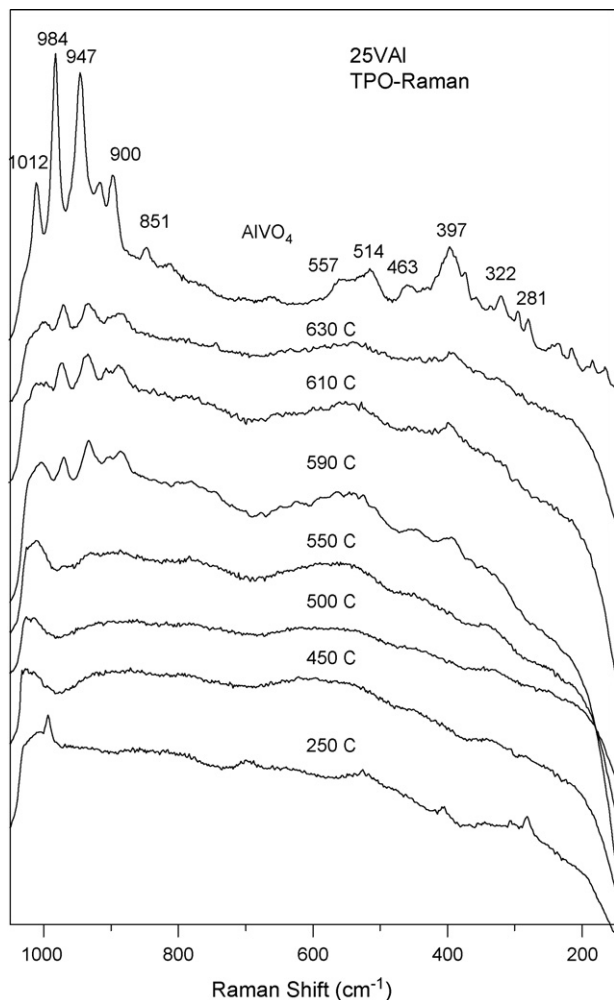


Fig. 2. Representative in situ TPO-Raman spectra of 25VAI. AlVO<sub>4</sub> is included for reference on top of all spectra.

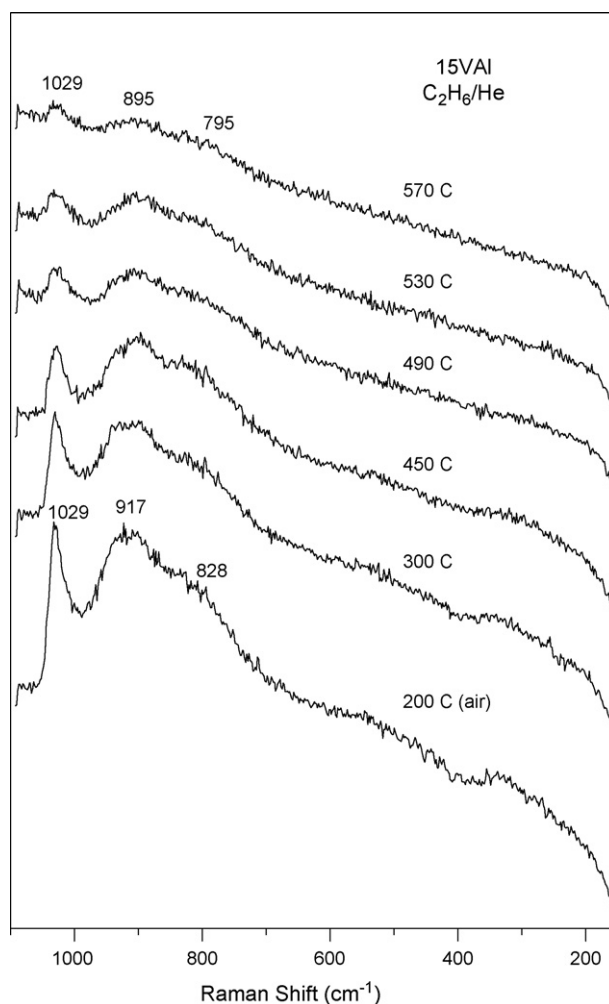


Fig. 3. Representative in situ TPR-Raman under C<sub>2</sub>H<sub>6</sub>/He of 15VAI.

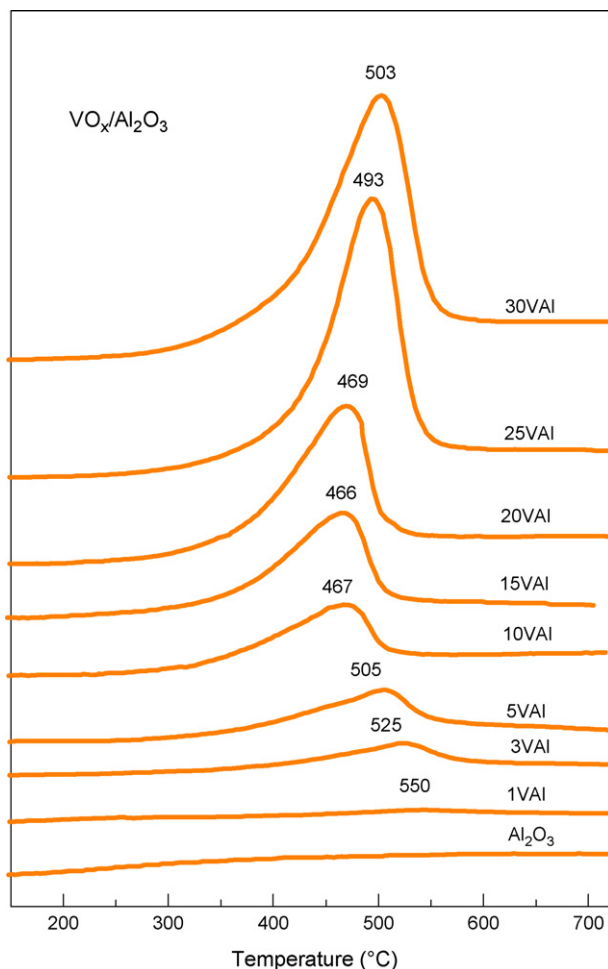


Fig. 4. H<sub>2</sub>-TPR profile of VO<sub>x</sub>/Al<sub>2</sub>O<sub>3</sub> catalysts.

acid sites (LAS) exhibit IR bands at 1450 and 1578 cm<sup>-1</sup> and the surface Brønsted acid sites (BAS) vibrations occur at 1450 and 1638 cm<sup>-1</sup>. The alumina support only possess surface LAS and surface BAS start to appear at 3 V/nm<sup>2</sup> and higher loadings. Vanadia species must titrate the alumina LAS.

The relationship between ratio of number of surface Brønsted acid sites (NBAS) (1538 cm<sup>-1</sup>) and number of surface Lewis acid sites (NLAS) (1450 cm<sup>-1</sup>) (NBAS/NLAS) versus vanadia loading is plotted in Fig. 6 along with the reducibility data and degree of polymerization of the surface VO<sub>x</sub> species [6]. The number of the surface Lewis acid sites of the VO<sub>x</sub>/Al<sub>2</sub>O<sub>3</sub> catalysts decreases with V<sub>2</sub>O<sub>5</sub> loading suggesting that they mainly originate from exposed alumina sites. No surface Brønsted acid sites are detected up to approximately half a monolayer of surface vanadia species on alumina and further increase with increasing surface vanadia coverage. The number of surface Brønsted acid sites reaches a maximum at ~20 wt.% of V<sub>2</sub>O<sub>5</sub> (9.9 V at/nm<sup>2</sup>) corresponding to monolayer coverage. Above monolayer surface vanadia coverage, the number of surface BAS slightly decreases when the crystalline V<sub>2</sub>O<sub>5</sub> nanoparticles are present on top of the surface VO<sub>x</sub> monolayer and cover some of the surface vanadia species. Similar trends were also reported by Akbas et al. [23]. Increasing the surface vanadia coverage in the sub-

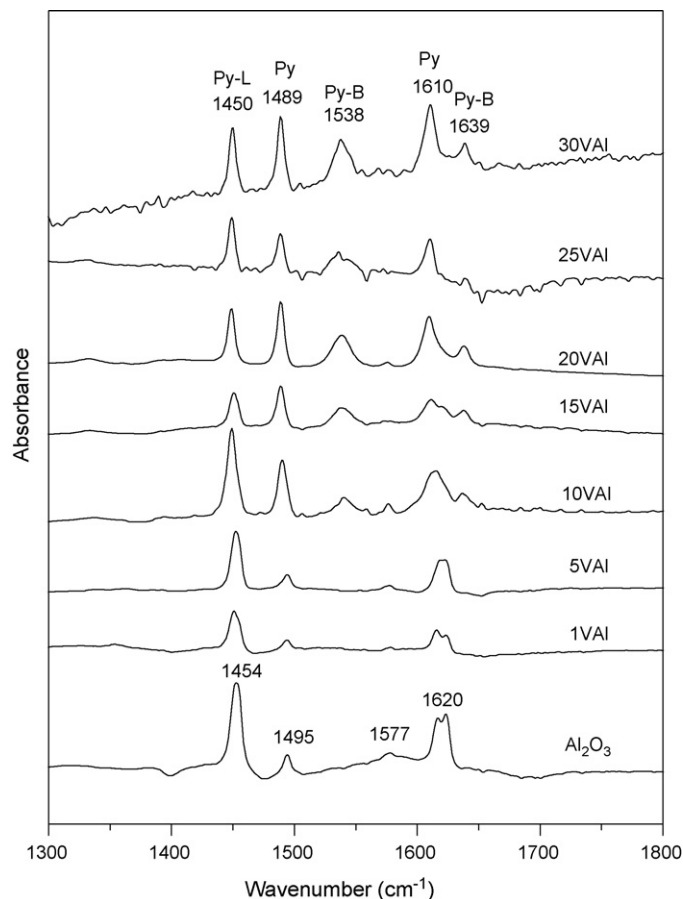


Fig. 5. FTIR spectra using pyridine adsorption.

monolayer region also promotes the reducibility of supported VO<sub>x</sub> species up to ca. 9.9 V at/nm<sup>2</sup>. It is interesting to observe that both trends parallel the continuous increase in the polymerization degree of the surface vanadia species as shown in Fig. 6 [6].

### 3.2. Oxidative dehydrogenation of ethane

The ethane ODH catalytic performance data are listed in Table 2 for reaction temperatures of 470, 510 and 550 °C. As expected, ethane conversion increases with reaction temperature since the Arrhenius rate increases with temperature. Ethane conversion initially increases with vanadia loading up to 20VAI (9 V/nm<sup>2</sup>), and then decreases with additional vanadia loading. At low vanadia loading, the selectivity towards CO and CO<sub>2</sub> are high. With increasing surface vanadia loading, the CO<sub>2</sub> selectivity decreases and the CO selectivity passes through a minimum at 5VAI (2.25 V/nm<sup>2</sup>). The ethylene selectivity varies inversely to that of the CO selectivity, reaching its maximum selectivity at 5VAI (2.25 V/nm<sup>2</sup>).

The product yields are illustrated in Fig. 7. Pure alumina is not selective and essentially yields CO and CO<sub>2</sub>. Addition of vanadia increases ethane conversion and formation of the selective ethylene product. The selectivity trends commented above and the continuous increase in the conversion values result in maximum yield to ethylene for 10–20% VO<sub>x</sub>/Al<sub>2</sub>O<sub>3</sub>

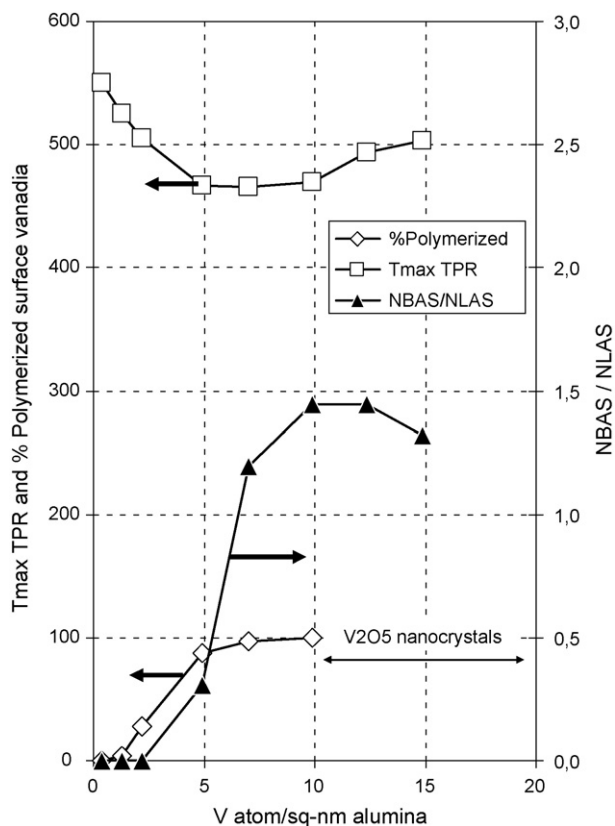


Fig. 6. Reducibility, extent of polymerization and NBAS/NLAS ratio vs. surface vanadium density.

(4.5–9 V/nm<sup>2</sup>) catalysts. In this loading range, ethylene production is essentially constant, but CO production increases.

In order to assess the activity per vanadium site and to better understand ethane ODH conversion over the alumina-supported vanadia catalysts, the specific TOF values to ethylene, CO and CO<sub>2</sub> at 470 °C are shown in Fig. 8A. The TOF values to CO increase at loading above monolayer surface vanadia coverage, which coincides with the appearance of crystalline V<sub>2</sub>O<sub>5</sub> nanoparticles. In general, the TOF for ethylene passes through a maximum and that for CO, through a minimum with surface vanadia coverage in the sub-monolayer region. In summary, the overall ethane consumption TOF does not change significantly with surface vanadia coverage, but the selectivity to the different products is strongly affected by surface vanadia coverage. The increase in selectivity with initial coverage of vanadia must be due to the titration of non-selective exposed alumina sites. At higher surface vanadia coverage, conversion of ethane increase and secondary reactions of ethylene are enhanced.

The number of surface vanadium sites involved in the rate-determining-step (rds) of ethane ODH to ethylene can be determined by the simplified rate equation

$$r \left[ \frac{\text{moles}}{\text{g} \times \text{s}} \right] = k' P_{\text{C}_2\text{H}_6} V^n$$

$$k' = k_{\text{RDS}} \times K_{\text{ADS}}$$

where  $V$  represents the vanadia atoms per gram of catalyst,  $k_{\text{RDS}}$  is the kinetic rate constant of the rate-determining-step (rds),

Table 2

The ethane ODH catalytic performance data of VO<sub>x</sub>/Al<sub>2</sub>O<sub>3</sub> catalysts for 470, 510 and 550 °C

Catalyst	T (°C)	Conversion (%)	Selectivity (%)		
			C <sub>2</sub> H <sub>4</sub>	CO <sub>2</sub>	CO
Al <sub>2</sub> O <sub>3</sub>	470	2.0	8	38	55
1VAI	470	0.6	24	26	51
3VAI	470	1.2	62	8	31
5VAI	470	1.9	79	3	21
10VAI	470	5.8	71	6	20
15VAI	470	6.9	69	2	29
20VAI	470	8.0	60	5	35
25VAI	470	12.1	41	6	53
30VAI	470	11.6	49	5	46
Al <sub>2</sub> O <sub>3</sub>	510	5.7	7	34	59
1VAI	510	1.6	27	22	51
3VAI	510	2.7	60	8	32
5VAI	510	3.7	72	4	24
10VAI	510	12.0	68	6	25
15VAI	510	13.6	56	5	39
20VAI	510	18.5	45	5	49
25VAI	510	23.2	30	8	62
30VAI	510	22.8	37	6	57
Al <sub>2</sub> O <sub>3</sub>	550	13.7	6	33	60
1VAI	550	5.2	27	21	52
3VAI	550	6.9	59	7	34
5VAI	550	9.2	70	4	26
10VAI	550	30.7	57	8	35
15VAI	550	32.8	40	5	55
20VAI	550	40.6	26	9	65
25VAI	550	35.7	23	11	67
30VAI	550	34.3	27	9	64

$K_{\text{ADS}}$  is the ethane equilibrium adsorption constant,  $P_{\text{C}_2\text{H}_6}$  is the partial pressure of ethane (mol<sup>-1</sup>), and “ $n$ ” represents the number of surface VO<sub>4</sub> species or catalytic active sites involved in the ethane ODH rate-determining-step. At constant temperature and ethane partial pressure, the value of “ $n$ ” can be determined directly from the slope of the plot of log  $r$  versus log  $V$  as the surface vanadia coverage is varied in the

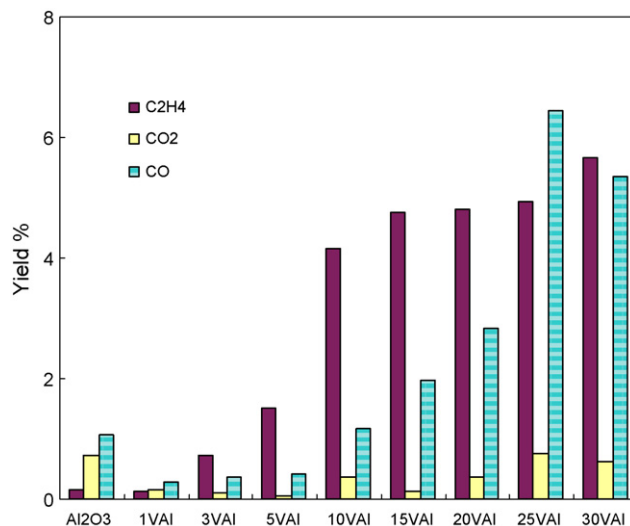
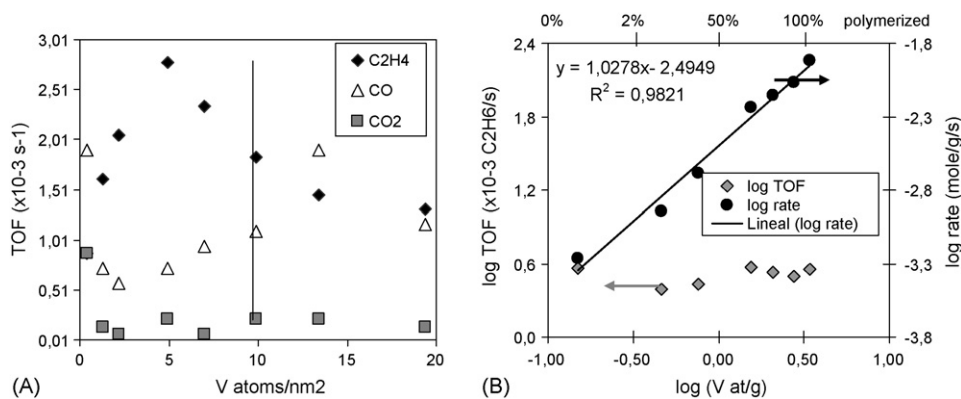


Fig. 7. Yield of C<sub>2</sub>H<sub>4</sub>, CO<sub>2</sub> and CO at 470 °C of VO<sub>x</sub>/Al<sub>2</sub>O<sub>3</sub> catalysts.

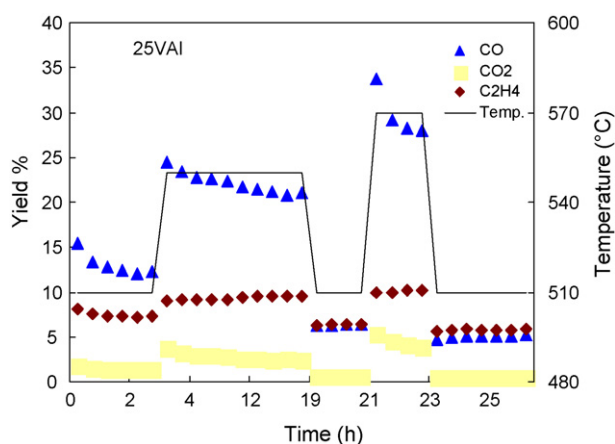
Fig. 8. TOF to ethylene, CO<sub>2</sub> and CO at 470 °C.

sub-monolayer region where vanadia is 100% dispersed as surface vanadia species on the Al<sub>2</sub>O<sub>3</sub> support. Fig. 8B illustrates such a kinetic plot, the ethane ODH TOF values, and the polymerization degree of surface vanadia species. The ethane ODH TOF values are not affected by vanadia coverage (i.e., polymerization degree). The plot of the rate yields a slope of  $\sim 1$ , which indicates that only one surface VO<sub>4</sub> site is involved in the rds for ethane ODH to ethylene.

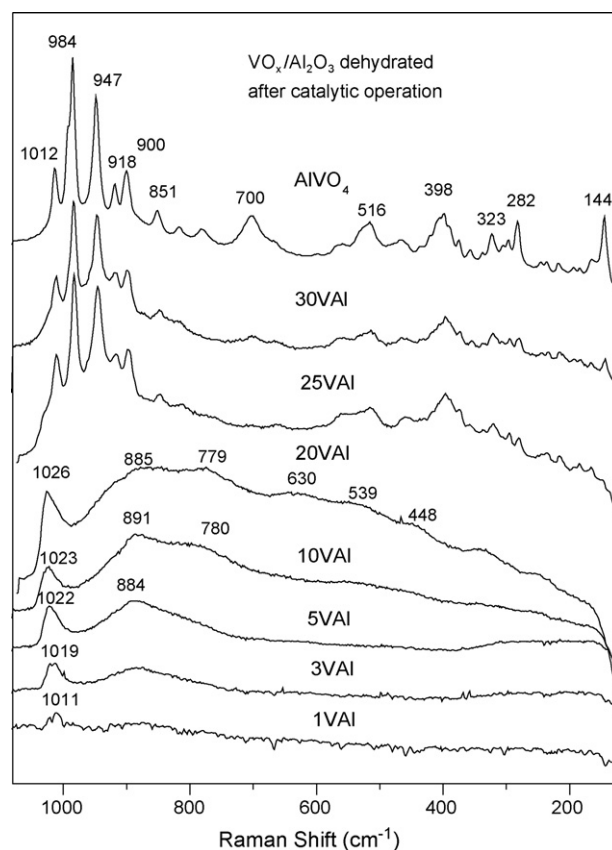
During the ethane ODH reaction, most of the supported VO<sub>x</sub>/Al<sub>2</sub>O<sub>3</sub> catalysts are stable during time on stream. However, catalysts with 10–30% VO<sub>x</sub>/Al<sub>2</sub>O<sub>3</sub> (4.5–13.5 V/nm<sup>2</sup>) do experience deactivation with time on stream, and the extent of deactivation increases with additional vanadia in this region. Fig. 9 illustrates the yield values of 25VAI (11.25 V/nm<sup>2</sup>) versus time on stream at different reaction temperatures. The CO and CO<sub>2</sub> yield values decrease with reaction time at a given temperature, but the ethylene yield values do not change. The extent of deactivation increases with increasing reaction temperature.

### 3.3. Characterization of used catalysts

In order to fundamentally understand the deactivation process on a molecular level, Raman spectra of dehydrated

Fig. 9. Yields of CO, CO<sub>2</sub> and C<sub>2</sub>H<sub>4</sub> vs. time as function of temperature for 25VAI catalyst.

spent catalysts were examined (see Fig. 10). The temperature was never above 570 °C. No significant structural changes are evident up to 20VAI (9 V/nm<sup>2</sup>), but significant structural differences are apparent for loadings above 20VAI (9 V/nm<sup>2</sup>). New Raman bands are present in the used 25VAI (11.25 V/nm<sup>2</sup>) and 30VAI (13.5 V/nm<sup>2</sup>) catalysts. These new and intense bands reflect the formation of crystalline AlVO<sub>4</sub>, which is included in the figure for reference purposes (Fig. 10). These results underline that the solid-state reaction between the alumina support and supported vanadia to form crystalline AlVO<sub>4</sub> under ethane ODH reaction conditions, and may be related to the observed catalyst deactivation.

Fig. 10. Raman spectra of dehydrated spent VO<sub>x</sub>/Al<sub>2</sub>O<sub>3</sub> catalysts after catalytic operation.

#### 4. Discussion

Alumina-supported vanadium oxide catalysts possess dispersed surface vanadium oxide species up to  $\sim 9 \text{ V/nm}^2$ , which corresponds to monolayer surface vanadia coverage on the alumina support. The analytical results from both XPS surface analysis of the V/Al atomic ratio and the absence of Raman vibrations for crystalline  $\text{V}_2\text{O}_5$  particles indicate that monolayer surface vanadia coverage corresponds to  $\sim 9 \text{ V/nm}^2$ . As the vanadia coverage increases in the sub-monolayer region ( $< 9 \text{ V/nm}^2$ ), the surface vanadia species begin to polymerize and the extent of polymerization increases with coverage [6]. Above monolayer surface vanadia coverage, three-dimensional crystalline  $\text{V}_2\text{O}_5$  nanoparticles also form on top of the two-dimensional surface vanadia monolayer.

As the surface vanadia coverage increases in the sub-monolayer region, several simultaneous trends take place with the surface  $\text{VO}_x$  species: formation of dehydrated polymeric species, increased reducibility and increase in Brønsted acidity. The extent of polymerization of the surface vanadia species increases with increasing surface vanadia coverage. The extent of polymerization can be quantitatively determined by UV–vis diffuse reflectance spectroscopy as has recently been reported [6]. The reducibility of the surface vanadia species increases as reflected in the lower  $\text{H}_2$ -TPR temperatures with increasing surface vanadia coverage. Almost all of the surface vanadia species become polymerized at 15VAI ( $7 \text{ V/nm}^2$ ), which corresponds to the most reducible catalyst (see Fig. 8). The overall reducibility of the supported  $\text{VO}_x/\text{Al}_2\text{O}_3$  catalysts decreases above 20VAI ( $9 \text{ V/nm}^2$ ) because of the presence of the crystalline  $\text{V}_2\text{O}_5$  nanoparticles above monolayer coverage. Raman directly confirmed the presence of the  $\text{V}_2\text{O}_5$  nanoparticles for 25VAI ( $11.25 \text{ V/nm}^2$ ) and 30VAI ( $13.5 \text{ V/nm}^2$ ). Thus, the  $\text{H}_2$  reducibility of the different supported vanadia species follows the trend: polymeric surface  $\text{VO}_x >$  isolated surface  $\text{VO}_x >$  crystalline  $\text{V}_2\text{O}_5$  nanoparticles. It is important to emphasize that the terminal  $\text{V}=\text{O}$  bond of surface vanadia species become stronger with coverage, shifts from 1010 to  $1023 \text{ cm}^{-1}$ , while the surface vanadia species become increasingly reducible. Thus, the terminal  $\text{V}=\text{O}$  bond must not be involved in the rate-determining-step of  $\text{H}_2$  reduction of the surface vanadia species.

The bare alumina support only possesses surface Lewis acid sites with the pyridine chemical probe molecule. The deposition of the surface vanadia species to the alumina support progressively titrate the alumina surface Lewis acid sites. At low surface vanadia coverage, surface Brønsted acid sites are not detected with pyridine. As the surface vanadia species become increasingly polymerized, the surface Brønsted acid sites start to appear. The increase in extent of polymerization of the surface vanadia species parallels the growth of surface Brønsted acid sites with surface vanadia coverage. It, thus, appears that the surface Brønsted acid sites are also associated with the polymeric surface vanadium oxide species on the  $\text{Al}_2\text{O}_3$  support. In summary, the acid-base and redox properties of the surface vanadia species on  $\text{Al}_2\text{O}_3$  in the sub-monolayer region are strongly influenced by the extent of polymerization.

The ethane ODH activity data exhibits a continuous increase in ethane conversion with vanadia loading that reaches a plateau or slight maximum at  $\sim 25\text{VAI}$  ( $11.25 \text{ V/nm}^2$ ). Higher vanadia loading slightly decreases the overall activity indicating that the crystalline  $\text{V}_2\text{O}_5$  nanoparticles are less active for ethane activation than the surface vanadia species on the alumina support. Note also that the unselective  $\text{CO}_x$  formation by the alumina support sites is progressively suppressed with increasing vanadia loading. Normalizing the catalytic activity per vanadium site (i.e., TOF number) allows the determination of the relative contributions of the isolated and polymeric surface  $\text{VO}_x$  species for ethane activation. The essentially constant ethane conversion TOF with surface vanadia coverage in the sub-monolayer region demonstrates that the rates of ethane activation by the isolated and polymeric surface vanadia species are essentially indistinguishable. In addition, the kinetic plot of  $\log \text{rate vs. } \log V$  also demonstrates that *only one surface  $\text{VO}_4$  site is involved in the rds for ethane ODH activation* (Fig. 8B). Thus, the activation of ethane is a structure-insensitive reaction over supported  $\text{V}_2\text{O}_5/\text{Al}_2\text{O}_3$  catalysts since this reaction does not require an ensemble of surface  $\text{VO}_x$  catalytic active sites. Similar trends are demonstrated for propane oxidative dehydrogenation reaction [6]. This effect depends on the specific substrate, for instance, butane oxidation to maleic anhydride does require an ensemble to surface  $\text{VO}_x$  active sites to produce maleic anhydride efficiently; in such case, activity increases dramatically with coverage [24].

Crystalline  $\text{AlVO}_4$  particles form at elevated temperature in the presence of the crystalline  $\text{V}_2\text{O}_5$  nanoparticles above monolayer surface vanadia coverage (see Fig. 2). In general, crystalline  $\text{AlVO}_4$  is observed at high vanadia loading on alumina support, particularly upon reducing conditions [10]. TPO shows incipient formation of  $\text{AlVO}_4$  at  $630^\circ\text{C}$ , however, ethane ODH reaction affords significant formation of  $\text{AlVO}_4$  at  $570^\circ\text{C}$ . The formation of  $\text{AlVO}_4$  is further accelerated in the ethane ODH reaction environment and its appearance parallels deactivation of the catalyst (see Fig. 9). The formation of crystalline  $\text{AlVO}_4$  appears to proceed by solid-state reaction between the crystalline  $\text{V}_2\text{O}_5$  nanoparticles and the  $\text{Al}_2\text{O}_3$  support. The interaction between vanadium and aluminum cations becomes increasingly important under reducing conditions, since reduced  $\text{V}^{3+}$  cations appear to be more compatible with the  $\text{Al}^{3+}$  cations [16]. Thus, reduced vanadia sites would interact more intensely with alumina support. The redox nature of ethane ODH reaction implies reduction–reoxidation cycles of vanadia sites. Thus, the solid-state reaction to form  $\text{AlVO}_4$  during ethane ODH seems to be favored by consecutive cycles of oxidation/reduction.

The formation of  $\text{AlVO}_4$  coincides with decreasing activity towards the non-selective oxidation products,  $\text{CO}$  and  $\text{CO}_2$ , but ethylene production is hardly affected (Fig. 9). This is probably due to the removal of  $\text{V}_2\text{O}_5$  nanocrystals.

#### 5. Conclusions

Supported vanadia catalysts consist of surface  $\text{VO}_x$  species in the sub-monolayer region ( $< 9 \text{ V/nm}^2$ ). The surface vanadia



species become progressively polymerized with loading until monolayer surface coverage is reached. The polymeric surface  $\text{VO}_x$  species are more reducible and possess more Brønsted acid character than the isolated surface  $\text{VO}_x$  species. Comparison of the surface vanadia molecular structures with the reducibility trend demonstrated that the terminal  $\text{V}=\text{O}$  bond is not involved in the reduction rate-determining-step. The surface vanadia species coordinate to the alumina support surface and cover the exposed alumina surface Lewis acid sites. These changes in surface acidity properties, however, do not affect the activation of ethane since the ethane TOF is constant with surface vanadia coverage. This finding suggests that the bridging  $\text{V}-\text{O}-\text{V}$  bond is not critical for activation of ethane and that the catalytic active site is associated with the bridging  $\text{V}-\text{O}-\text{Al}$  bond. At low surface vanadia coverage, the exposed strong alumina Lewis acid sites are responsible for  $\text{CO}$  and  $\text{CO}_2$  formation and the low  $\text{C}_2\text{H}_4$  selectivity during ethane ODH. As these exposed alumina sites are progressively covered by the surface vanadia species, the vanadia-alumina system becomes more selective towards  $\text{C}_2\text{H}_4$  formation and suppresses  $\text{CO}_x$  formation. The maximum ethylene selectivity is observed at  $2.2 \text{ V/nm}^2$ , which corresponds to  $\sim 25\%$  surface vanadia monolayer. The decrease in ethylene selectivity above  $2.2 \text{ V/nm}^2$  appears to correspond with the increasing reducibility of the surface  $\text{VO}_x$  species and the presence of surface Brønsted acid sites. The crystalline  $\text{V}_2\text{O}_5$  nanoparticles are not active for ethane conversion, but do convert ethylene to unselective  $\text{CO}_x$ . At elevated temperatures the crystalline  $\text{V}_2\text{O}_5$  nanoparticles undergo solid-state reaction with the  $\text{Al}_2\text{O}_3$  support to form  $\text{AlVO}_4$ . This solid-state reaction also suppresses the conversion of ethylene to  $\text{CO}_x$  and, consequently, enhances the ethylene selectivity.

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